

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named

Inventor : Benjamin Y.H. Liu

Appln. No.: 10/769,011

Filed : January 30, 2004

For : HIGH-PERFORMANCE AND MULTI-
LIQUID-PRECURSOR VAPORIZATION
IN SEMICONDUCTOR THIN FILM
DEPOSITION

Docket No.: M419.12-0043

Group Art Unit: 1792

Examiner: Buckner, Richard R.

AMENDMENT

**FILED ELECTRONICALLY
FEBRUARY 23, 2009**

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Amendment is in response to the Official Action of January 29, 2009.

Please amend the above-identified application as follows.